



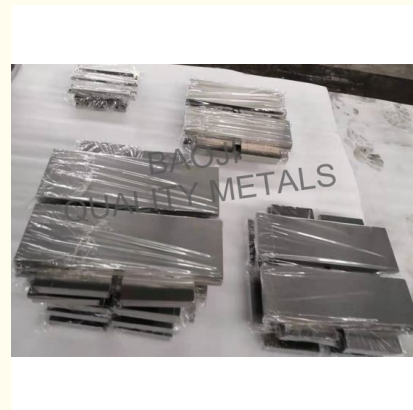
Pvd Titanium Sputtering Targets 99.6% , ASTM B265 Aluminum Titanium Alloy For Coating

Our Product Introduction

for more products please visit us on titanium-part.com

Basic Information

- Place of Origin: China
- Brand Name: N/M
- Certification: ISO9001:2015 certification
- Model Number: CDX--TB-2021019
- Minimum Order Quantity: Samples available
- Price: Negotiable
- Packaging Details: plywood case
- Delivery Time: 5-35 working days
- Supply Ability: 50000KG/month



Product Specification

- Keywords: High Purity Metal Target Titanium
- Application: Liquid Crystal Display, Laser Memory,
- Grade: Gr1
- Name: Titanium Niobium Target
- Ti Content (%): 99.6%, 99.99%, 99, 99.95%-99.999%, 95%
- Shape: Round, Customs Made, Round & Rectangle, Tube/ Plate, As Request
- Surface: Polished, Cleaning, CNC Lathe Surface, Pickled, Bright
- Product Name: Titanium Disc, titanium Bars, Chromium Aluminum Alloy, Ti Flat Sputtering Target, titanium Sputtering Target
- Standard: ASTM Standard B265 Grade1
- Highlight: **ASTM B265 Titanium Sputtering Targets, 99.6% Titanium Sputtering Targets, Aluminum Titanium Alloy Pvd Targets**



Product Description

Titanium Aluminum Alloy Pvd Targets/Titanium Sputtering Targets/TiAl Alloy Target For Coating

Square Pure Titanium Sputtering Target High Purity 99.995% Circular Ti Titanium Sputtering Target

Titanium sputtering target

PVD coating Grade 1 Titanium Arc Target Ti Target titanium sputtering target
target pure titanium target, MMO Coating Titanium Anode

★ Material	
Titanium	Gr. 1
Key words	Titanium target
Titanium sputtering target , target pure titanium target, MMO Coating Titanium Anode	
Application:	
◆ liquid crystal display, laser memory,	
◆ Electronic controller sputtering thin film material,	
◆ Semiconductor integrated circuits,	
◆ Solar photovoltaic, Recording medium,	
◆ Flat display, Workpiece surface coating etc..	

Tolerance	+/-0.01mm
Surface	Polished, Cleaning, CNC lathe surface, Pickled, bright
Dimensions	according customer's request.
Ti content(%)	99.96% 99.98% 99.99%
Density	4.51g/cm3
Color	titanium original color
Services: CNC , machining, turning, milling, stamping, casting, drilling, grinding, threading etc.	





Terms of trade	EXW, FOB, CIF
Terms of payment	T/T, L/C
Packing	plastic paper inside, plywood case outside.
Quality control	Ultrasonic testing & material test report
Delivery time	7-30 days
MOQ	Small order quantity is acceptable.
Business Type	Manufacturer, Foreign Trading

High purity and high density sputtering targets include:

Sputtering target (purity: 99.9% - 99.999%)

Titanium target titanium sputtering target is used for liquid crystal display, laser memory, electronic controller sputtering thin film materials, semiconductor integrated circuits, solar photovoltaic, recording media, plane display and workpiece surface coating

Q: Why choose us?

A1: We have 14 years experience for titanium products making.

A2: sample order is acceptable.

A3: lower price, good quality and short delivery time.

A4: The quotation can be made within 24 hours.

A5: ISO9001:2015 certification

A6: Give us drawing, make your drawings and ideas become a reality!

A7: Provide third-party quality inspection reports.

